

## Supplementary Information

### Thermally induced orientational flipping of cylindrical phase diblock copolymers

F. Ferrarese Lupi,<sup>a</sup> T.J. Giammaria,<sup>a,b</sup> G. Seguni,<sup>a</sup> M. Laus,<sup>b</sup> E. Enrico,<sup>c</sup> N. De Leo,<sup>c</sup> L. Boarino,<sup>c</sup> C.K. Ober,<sup>d</sup> M. Perego<sup>a</sup>

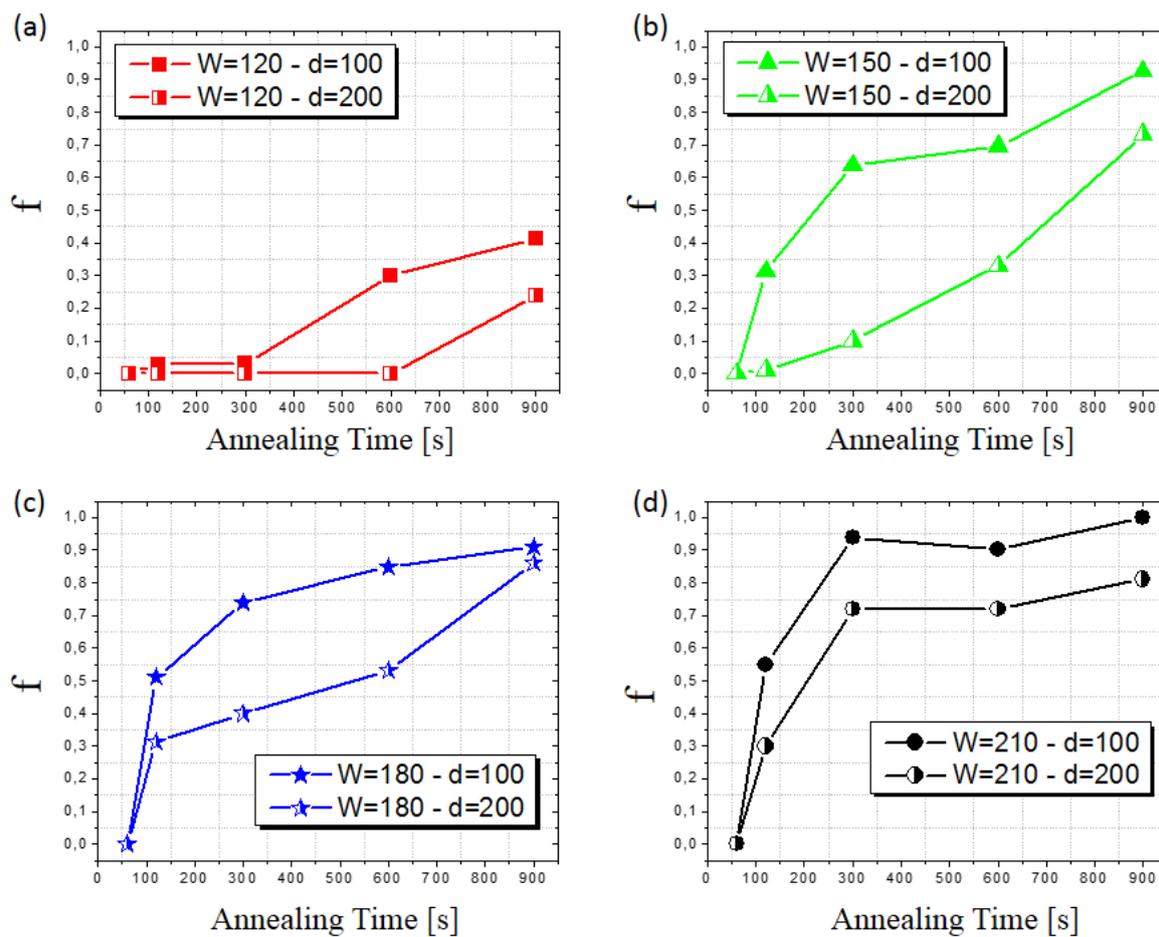
<sup>a</sup> Laboratorio MDM, IMM-CNR, Via C. Olivetti 2, 20864 Agrate Brianza (MB), Italy; Fax: 0039 039 6881175; Tel: 0039 039 6036383;

E-mail: federico.ferrareselupi@mdm.imm.cnr.it

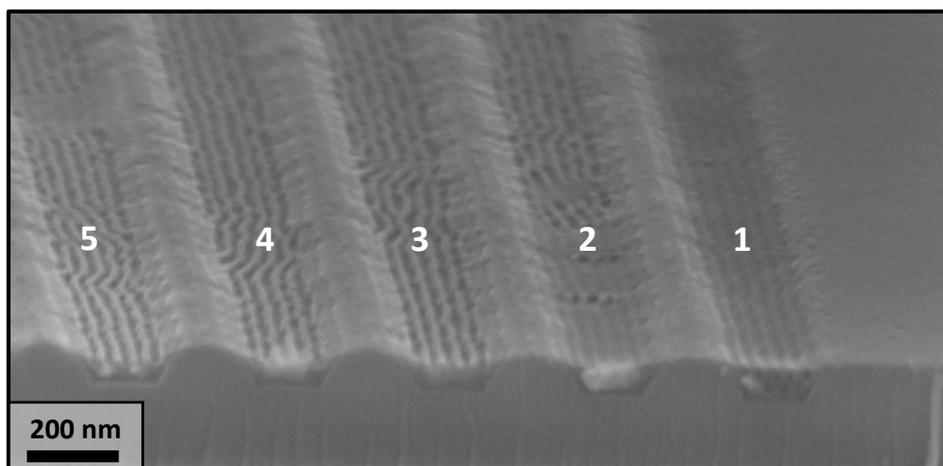
<sup>b</sup> Dipartimento di Scienze e Innovazione Tecnologica (DISIT), Università del Piemonte Orientale “A. Avogadro”, INSTM, UdR Alessandria, Viale T. Michel 11, 1512 Alessandria, Italy

<sup>c</sup> NanoFacility Piemonte, Istituto Nazionale Ricerca Metrologica, Strada delle Cacce 91, 10135 Torino, Italy

<sup>d</sup> Department of Materials Science and Engineering, Bard Hall, Cornell University, Ithaca, New York 14853



**Fig. S1** Fraction of perpendicularly organized areas  $f$  for different trench width ( $W = 120$  (a),  $W = 150$  (b)  $W = 180$  (c) and  $W = 210$  nm (d)) as a function of the trench distances  $d = 100$  nm and  $d = 200$  nm. In all the reported graphics, the flipping rate is higher for the group of trenches with smaller  $d$  values.



**Fig. S2** Cross-sectional scanning electron microscopy (SEM) image of cylinder-forming PS-b-PMMA deposited on a periodic topographic structure. The BCP were spun on the bare oxide without any previous functionalization and annealed at 250°C for 30 s. This process lead to a parallel disposition of the nanometric cylinders with respect to the substrate. A clear decrease of the BCP thickness inside the trenches from the peripheral (trench 1) to the central one (trench 5) is visible.